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PTO-1449A(10-01)

Approved for use through 10/31/2002. OMB 05-0271

U.S. Patent and Trademark Office U.S. DEPARTMENT OF COMMERCE

Complete if Known

Application Number	10/043065
Filing Date	January 9, 2002
First Named Inventor	Forbes, Leonard
Group Art Unit	2822
Examiner Name	Meier, Stephen

Attorney Docket No: 303.684US3

US PATENT DOCUMENTS

Examiner Initials*	USP Document Number	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	Filing Date If Appropriate
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FOREIGN PATENT DOCUMENTS

Examiner Initials*	Foreign Document No	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	T ²

OTHER DOCUMENTS – NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
KR		SHI, Y., et al., "Tunneling Leakage Current in Ultrathin (<4 nm) Nitride/Oxide Stack Dielectrics", IEEE Electron Device Letters, 19(10), (Oct. 1998), pp. 388-390	

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Substitute Disclosure Statement Form (PTO-1449)

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